## DOCUMENT . 3/7 **DOCUMENT NUMBER**

## DEPAIL JARANESE

@: unavailable

- 1. JP,2001-294539,A
- 2. JP,2000-325510,A
- 3. JP,2001-234356,A
- 4. JP,2001-149774,A
- 5. JP,2002-088487,A
- 6. JP,2002-144378,A
- 7. JP,2003-084332,A

## PATENT ABSTRACTS OF JAPAN

(11)Publication number:

2001-

234356

(43) Date of publication of application: 31.08.2001

(51)Int.Cl.

C23C 26/00 B05D 7/24

HO1B 5/14 H01B 13/00

(21)Application number: 2000-

(71)Applicant : SEIKO

**EPSON** 

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(22)Date of filing:

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## (54) PRODUCING METHOD OF FILM AND FILM OBTAINED THEREBY

047764

(57)Abstract:

PROBLEM TO BE

SOLVED: To provide

a method for inexpensively

producing an

electrically

conductive film

excellent in electric

conductivity.

SOLUTION: In this

producing method for

a film, a colloidal

layer is formed on a

base material, and

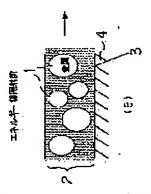
the surface of the

colloidal layer is

irradiated with an

energy ray which

imparts higher



absorption strength to the colloidal layer than to the base material. In particular, the above colloidal layer is composed of a metallic colloidal layer, and as the above film, an electrically conductive film is suitably obtained. Moreover, the film in this invention can be obtained by the above producing method.

